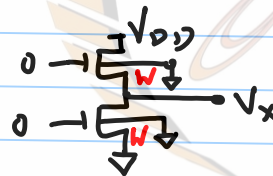
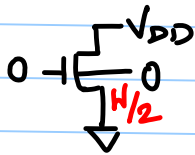


12/09/2019

EE5311

MODULE - 3 - THE INVERTER

STACKING EFFECT



ASSUMED:

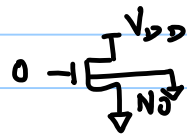
- 1) $n = 1$
- 2) BODY EFFECT $\gamma = 0$
- 3) DIBL $\eta = 0$
- 4) LARGE V_{DD} ($V_{DD} > 3\phi_t$)

$$I_{LEAK} = I_0 \frac{W}{2} e^{-\frac{V_T}{\phi_t}}$$

$$V_x = \phi_t \ln 2$$

$$\begin{aligned} I_{TOT} &= I_0 \cdot W e^{-\frac{V_T}{\phi_t}} (1 - e^{-V_x/\phi_t}) \\ &= I_0 \left(\frac{W}{2} \right) e^{-V_T/\phi_t} \end{aligned}$$

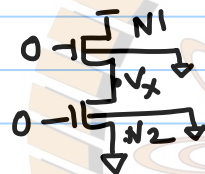
REALITY ($\gamma \neq 0, \eta \neq 0, n = 1.5$) ($V_{DD} > 3\phi_t$)



$$V_{DS} = V_{DD}$$

$$V_{SB} = 0$$

$$V_T = V_{TH0} - \eta V_{DD}$$



	V_{DS}	V_{SB}
N1	$(V_{DD} - V_x)$	V_x
N2	V_x (≈ 0)	0

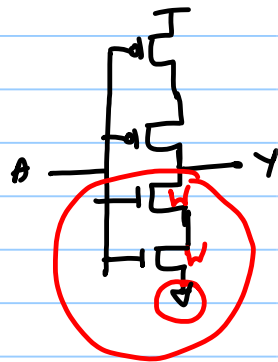
$$V_{TH} = V_{TH0} + \gamma (\sqrt{V_x + \phi_s} - \sqrt{1\phi_s}) - \eta (V_{DD} - V_x)$$

$$V_{TH0} - \eta V_x$$

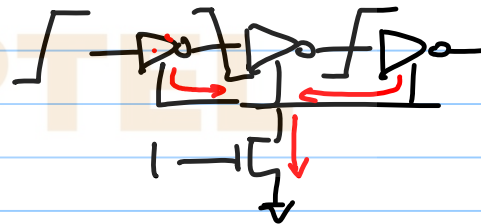
$$I_{STACK-2} \ll I_{STACK-1}$$

V_{TH} of N1 \uparrow COMPARED TO NO
~ BECAUSE OF

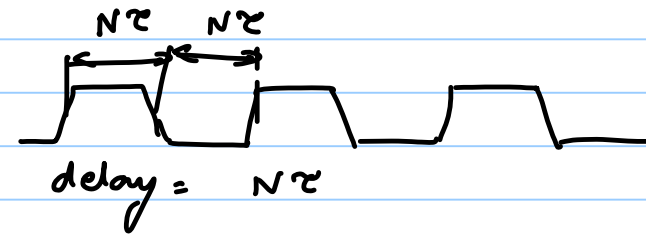
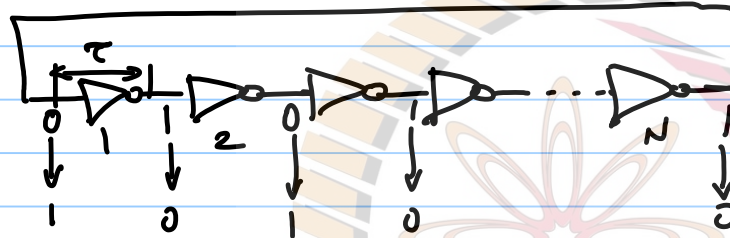
- (1) DIBL (DOMINATES)
- (2) BODY EFFECT



SLEEP = 1 (SLEEP MODE)



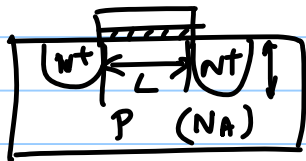
RING OSCILLATOR



$$f = 1/2N\tau$$

LARGE 'N'

PROCESS VARIATIONS:

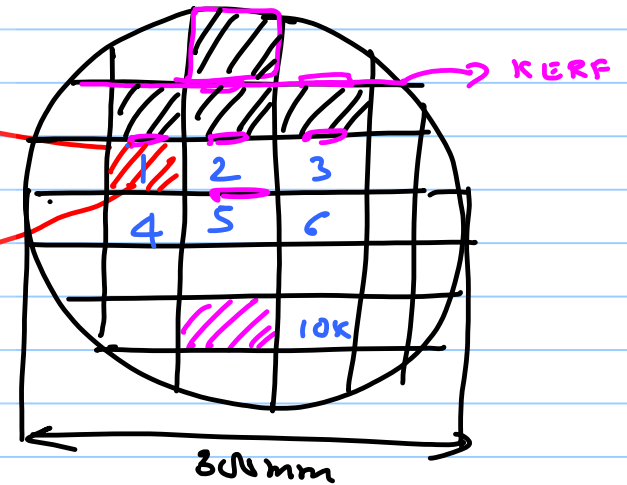
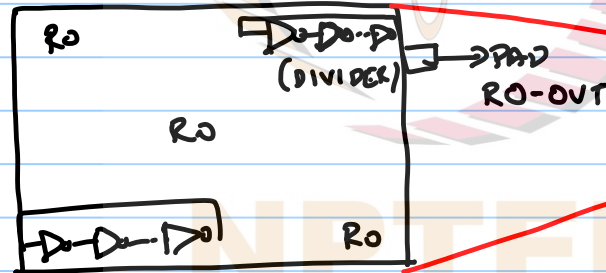


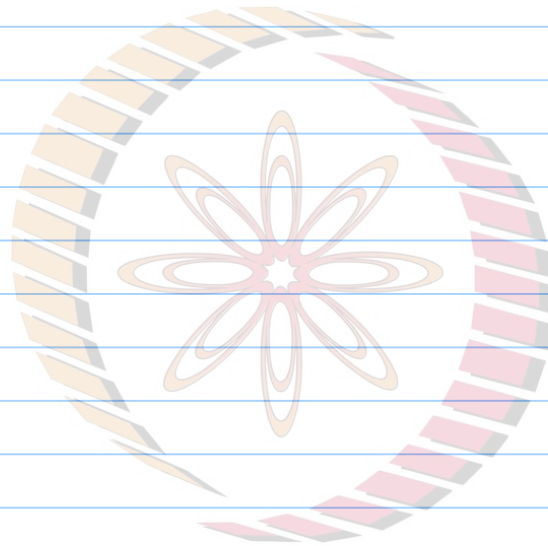
$$N_A \rightarrow 10^{15}/\text{cm}^3$$

1) LITHO CHANGES

2) RANDOM DOPANT FLUCTUATION (RDF) $\rightarrow \sigma_{VT} \propto 1/\sqrt{LW}$

GLOBAL PROCESS MONITOR





NPTEL